Min-Chuan Wang

List of Publications by Year in descending order

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1684188 1720034 9 89 5 7 citations g-index h-index papers 9 9 9 122 docs citations times ranked citing authors all docs

| # | Article | IF | CITATIONS |
|---|---|-----|-----------|
| 1 | A coaxial-type pulsed arc plasma doping process for the lithium-ion thin-film electrolyte application. Applied Physics Letters, 2020, 117 , . | 3.3 | 2 |
| 2 | The approach of in-situ doping ion conductor fabricated with the cathodic arc plasma for all-solid-state electrochromic devices. AIP Advances, $2018,8,.$ | 1.3 | 2 |
| 3 | A Method to Reduce Forming Voltage Without Degrading Device Performance in Hafnium Oxide-Based 1T1R Resistive Random Access Memory. IEEE Journal of the Electron Devices Society, 2018, 6, 341-345. | 2.1 | 29 |
| 4 | Super Critical Fluid Technique to Enhance Current Output on Amorphous Silicon-Based Photovoltaic. IEEE Electron Device Letters, 2017, 38, 1401-1404. | 3.9 | 11 |
| 5 | All-solid-state electrochromic device integrated with near-IR blocking layer for image sensor and energy-saving glass application. Applied Physics Letters, 2016, 109, . | 3.3 | 12 |
| 6 | The improvement of all-solid-state electrochromic devices fabricated with the reactive sputter and cathodic arc technology. AIP Advances, 2016, 6, 115009. | 1.3 | 12 |
| 7 | All-solid-state electrochromic device integrated with near-IR blocking layer for image sensor and energy-saving glass application. , $2016, $, . | | 1 |
| 8 | All-solid-state electrochromic thin films for optical iris application. , 2015, , . | | 1 |
| 9 | Effects of ZnO-nanostructure antireflection coatings on sulfurization-free Cu2ZnSnS4 absorber deposited by single-step co-sputtering process. Applied Physics Letters, 2013, 103, . | 3.3 | 19 |